

HICUM - Productization and Support Update

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http://www.iee.et.tu-dresden.de/iee/eb/hic_new/hic_start.html

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Overview

- HICUM/Level2 Version 2.2 release
- Test results
- Documentation
- Code/implementation related investigations
- Version 2.3 in progress
- HICUM/Level0

HICUM/L2 version 2.2 release

- Version 2.21 released in November' 2005
 - allow variable self heating model via flag FLSH
 - provide flexible flicker noise model
 - version control mechanism fixed
 - focus on v2.2 instead of v2.1
 - downward compatibility issues raised and primarily addressed
- Version 2.22 released in August' 2006
 - minor bugs in v2.21 fixed and code rearranged
 - all compatibility issues addressed and fixed
 - temperature related seven incompatible equations
 - incompatibility of collector current spreading
 - compatibility flag FLCOMP can have values of version number (e.g. 2.1)
 - thermal node set as external : issues with NODE COLLAPSING
 - hyperbolic smoothing in internal base resistance formulation

HICUM/L2 version 2.2 release (contd.)

downward *compatibility* issues (with respect to v2.1)

- Temperature related (presented in last CMC meeting)
 - Version 2.21 included
 - BE injection related saturation currents
 - BE recombination related saturation currents
 - equilibrium hole charge
 - emitter transit time
 - Version 2.22 additionally included
 - BC saturation currents
 - Substrate transistor transfer and SC saturation currents
 - Voltage separating ohmic and saturation velocity regime
- Collector minority charge in version 2.22
 - separate routine HICFCT for 2D/3D case like in V2.1

HICUM/L2 version 2.2 release (contd.)

internal base resistance

- equation of conductivity modulation

$$\text{v2.1:} \quad r_i = r_{Bi0} \left(\frac{Q_0}{Q_0 + \Delta Q_p} \right) = r_{Bi0} \left(\frac{Q_0}{Q_0 + Q_{jEi} + Q_{jCi} + Q_f} \right)$$

$$\text{v2.21:} \quad r_i = r_{Bi0} \left(\frac{Q_0}{Q_0 + \Delta Q_p} \right) = r_{Bi0} \left(\frac{Q_0}{Q_0 + Q_{jEi} + Q_f} \right)$$

$$\text{ADS2005:} \quad \Delta Q_{pm} = q_{0lim} + \frac{1}{2} [\Delta Q_p - q_{0lim} + \sqrt{(\Delta Q_p - q_{0lim})^2 + \delta^2}]$$

$$q_{0lim} = -0.75 Q_0 \quad \text{and} \quad \delta = Q_0 (T_0) \times 10^{-3}$$

$$r_i = r_{Bi0} \left(\frac{Q_0}{Q_0 + \Delta Q_{pm}} \right)$$

HICUM/L2 version 2.2 release (contd.)

internal base resistance

version 2.22 includes a solution simpler to ADS

- equation of conductivity modulation

$$r_i = r_{Bi0} \left(\frac{Q_0}{Q_0 + \Delta Q_p} \right) = r_{Bi0} \left(\frac{1}{\frac{q_r + \sqrt{q_r^2 + 0.01}}{2}} \right)$$

v2.22:

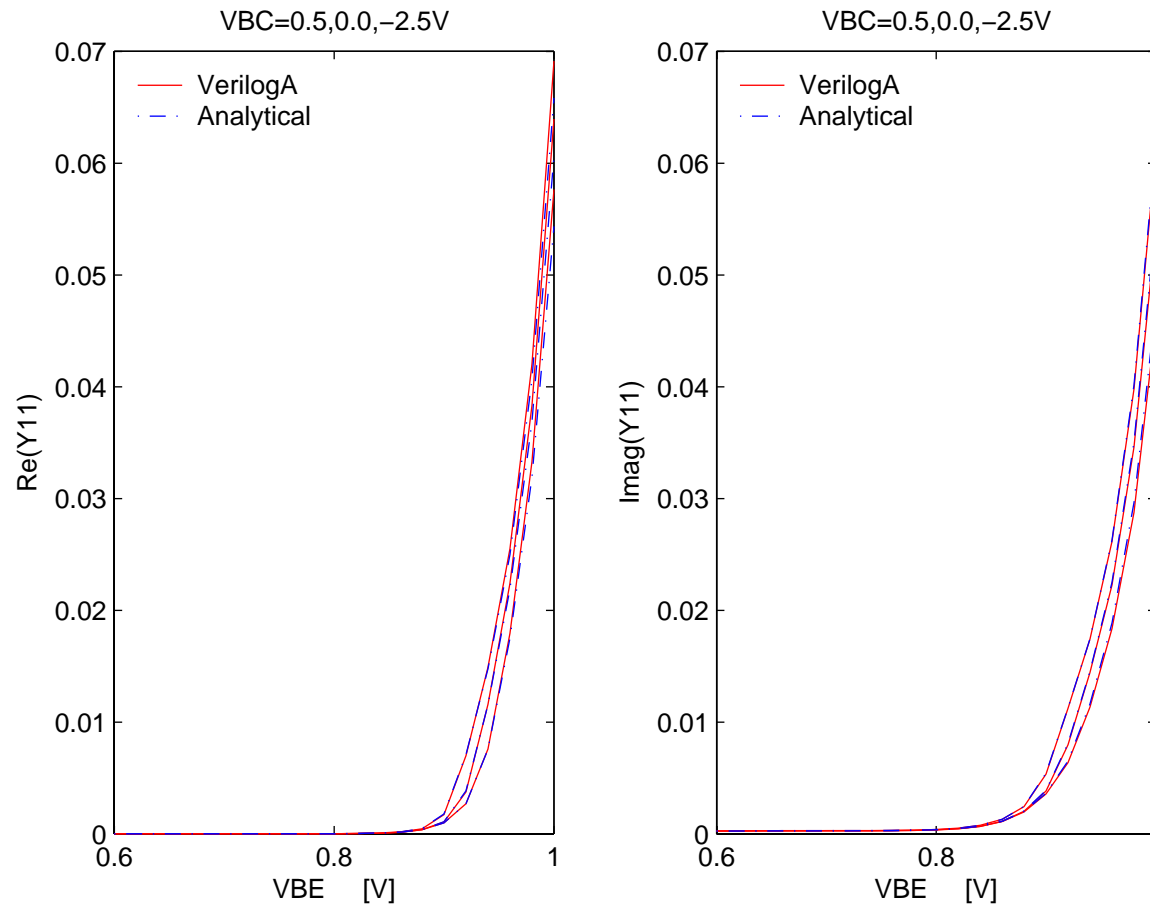
$$q_r = 1 + \frac{\Delta Q_p}{Q_0} = 1 + \frac{Q_{jEi} + Q_{jCi} + Q_f}{Q_0}$$

- Q_{jCi} included as in original model formulation
- numerical instability removed with hyperbolic smoothing

Test results

internal transistor model : Y11 plot at T=300K

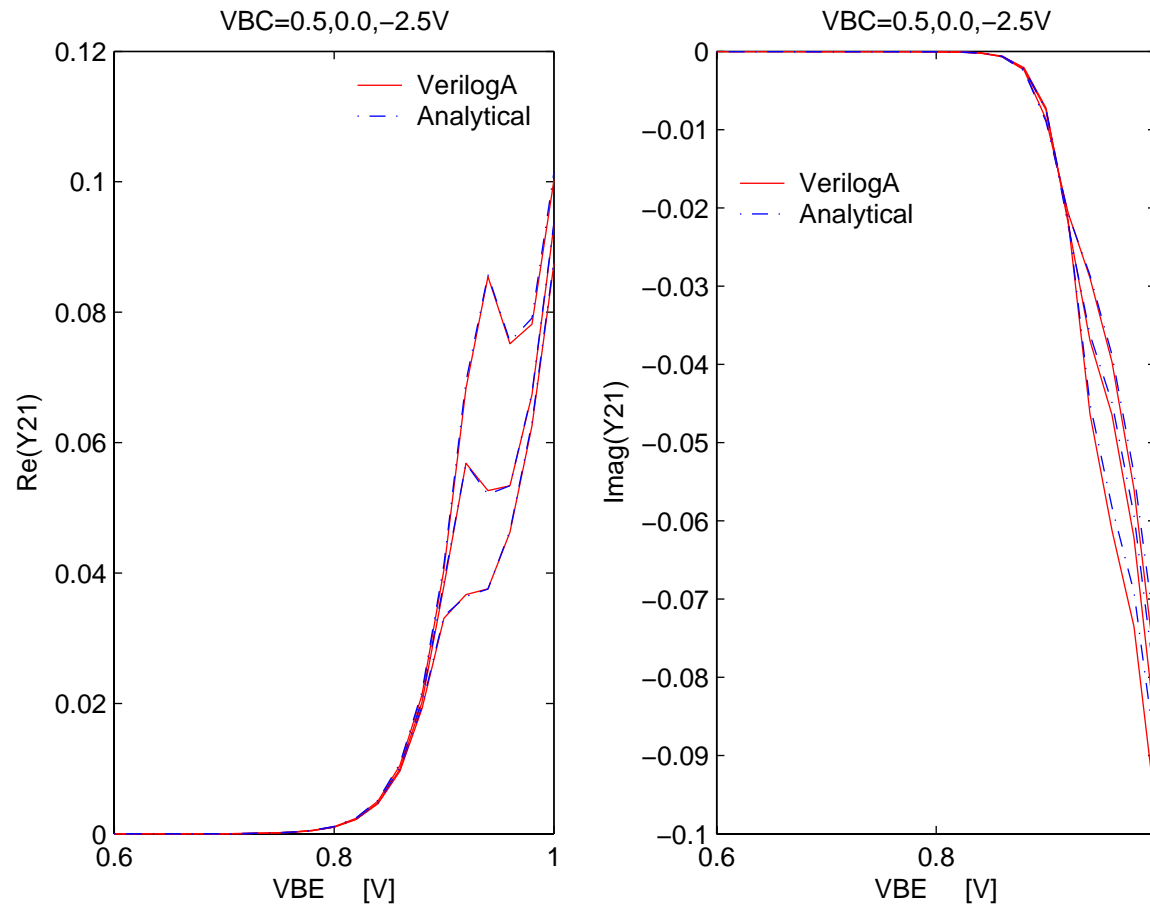
vbc=0.5,0.0,-2.5 V, Verilog-A v2.22: red, analytical: blue



Test results (contd.)

internal transistor model : Y21 plot at T=300K

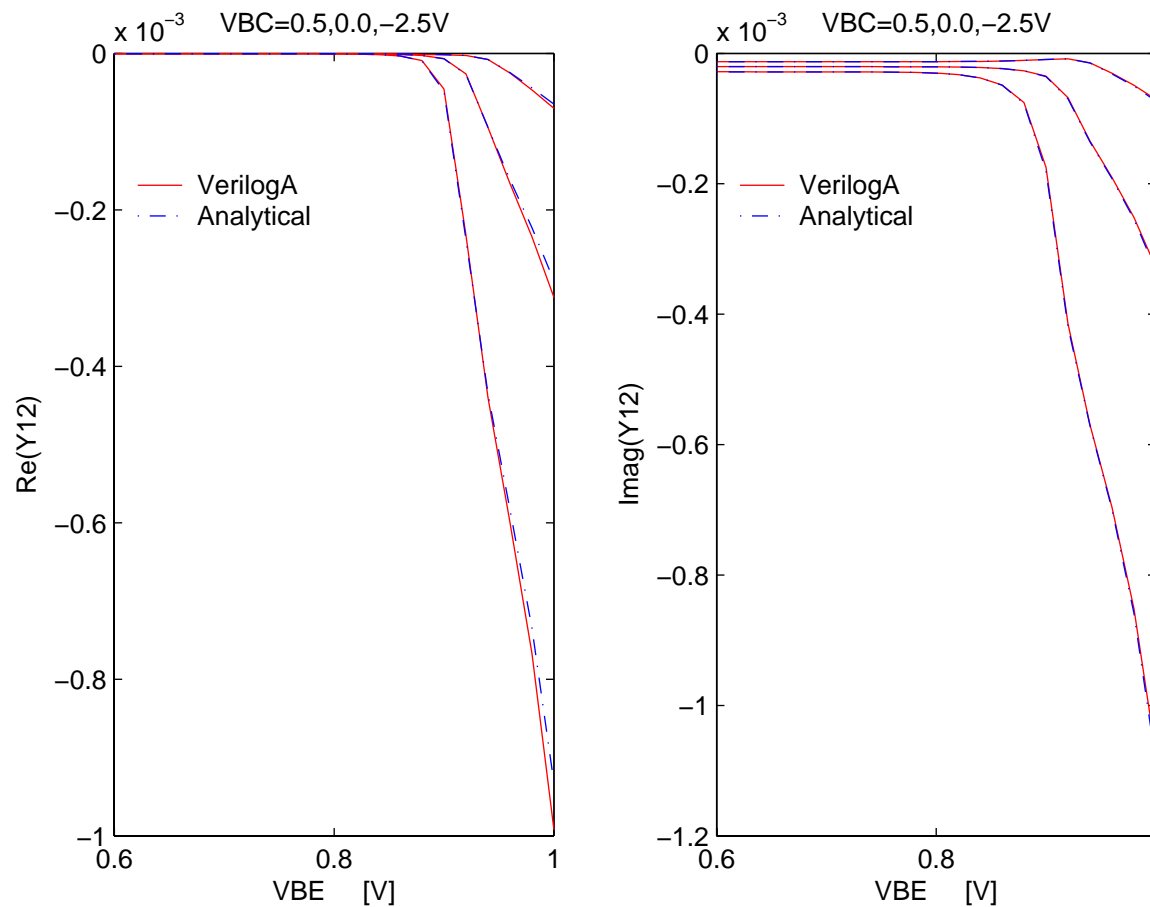
vbc=0.5,0.0,-2.5 V, Verilog-A v2.22: red, analytical: blue



Test results (contd.)

internal transistor model : Y12 plot at T=300K

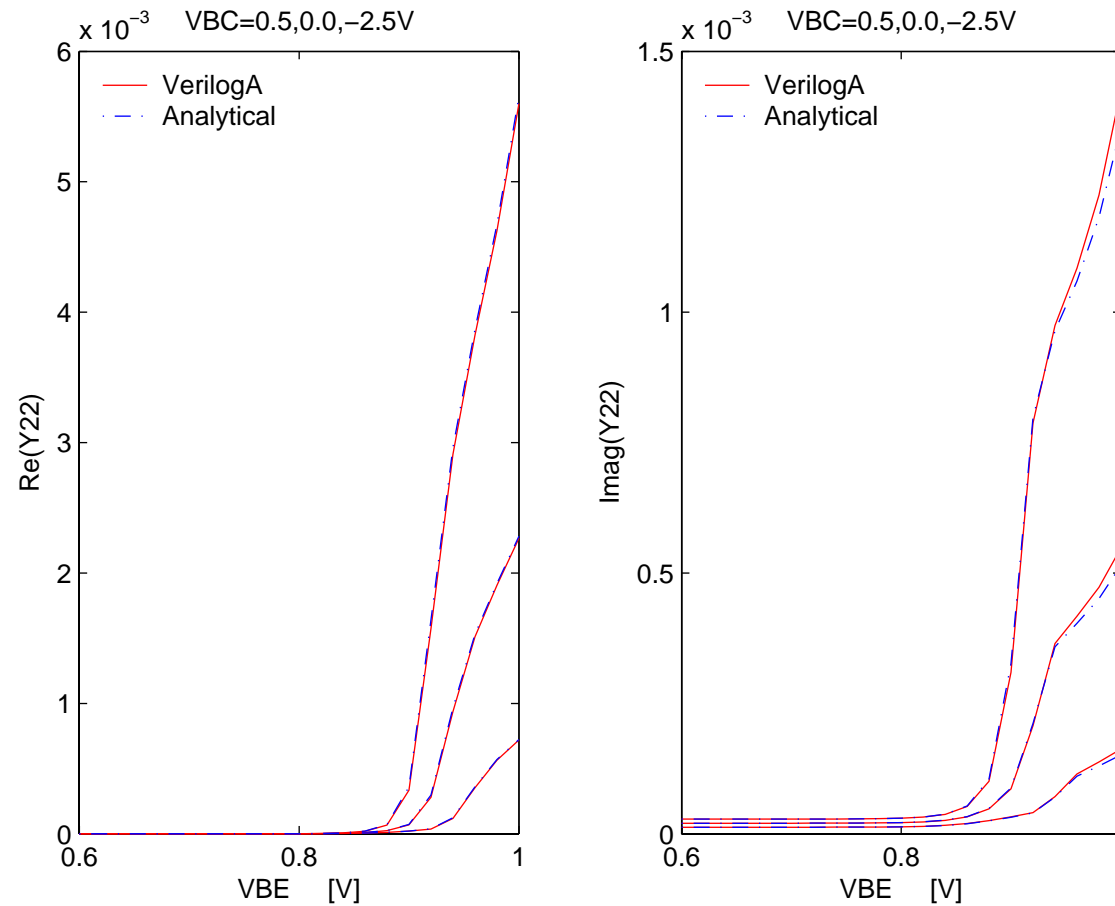
vbc=0.5,0.0,-2.5 V, Verilog-A v2.22: red, analytical: blue



Test results (contd.)

internal transistor model : Y22 plot at T=300K

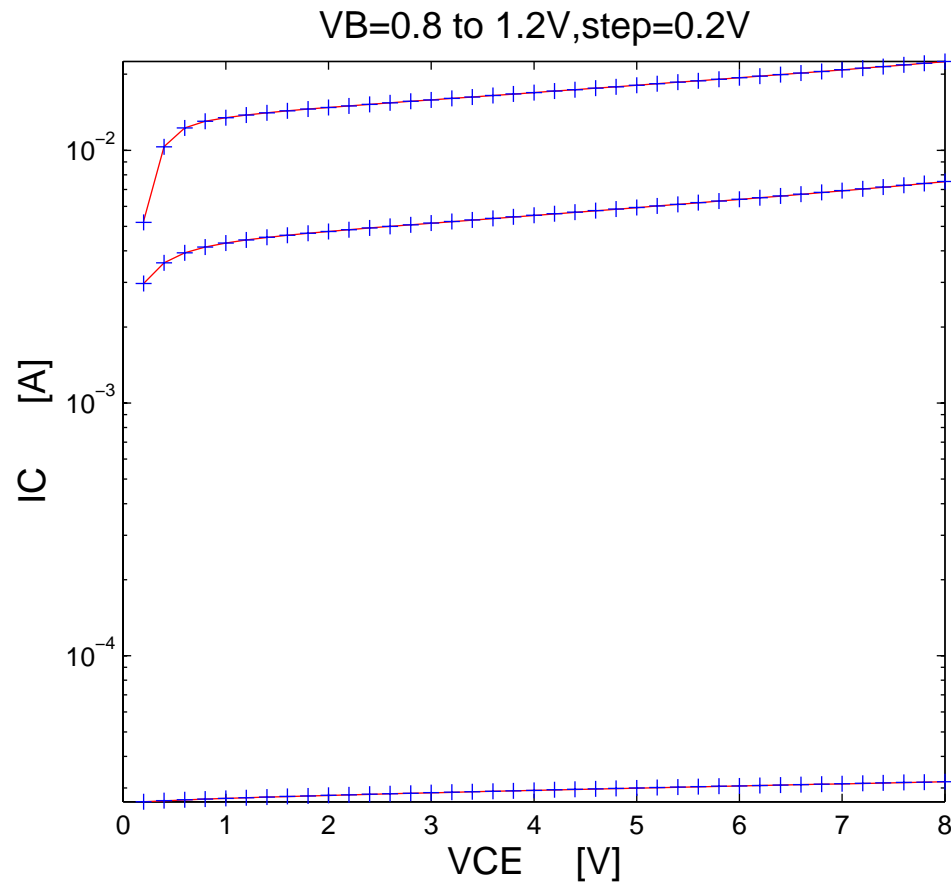
vbc=0.5,0.0,-2.5 V, Verilog-A v2.22: red, analytical: blue



Test results (contd.)

compatibility test with self-heating: output characteristics

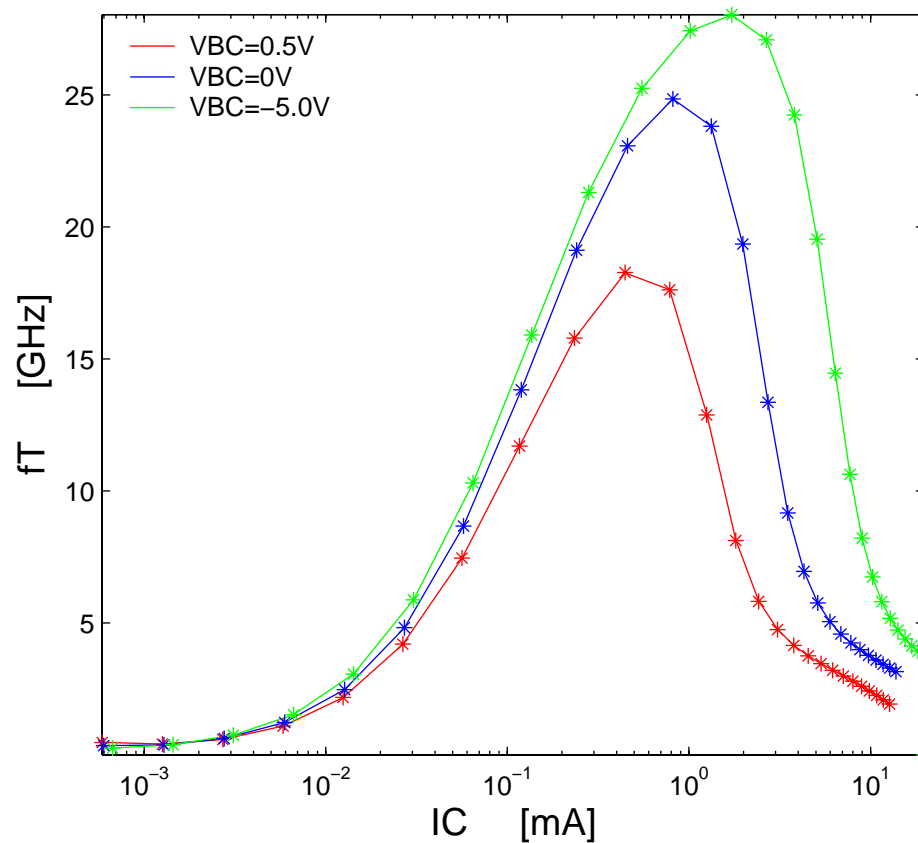
T=300K, FLSH=1, v2.22: continuous line, v2.11: symbols



Test results (contd.)

compatibility test with self-heating: transit frequency (@0.5GHz)

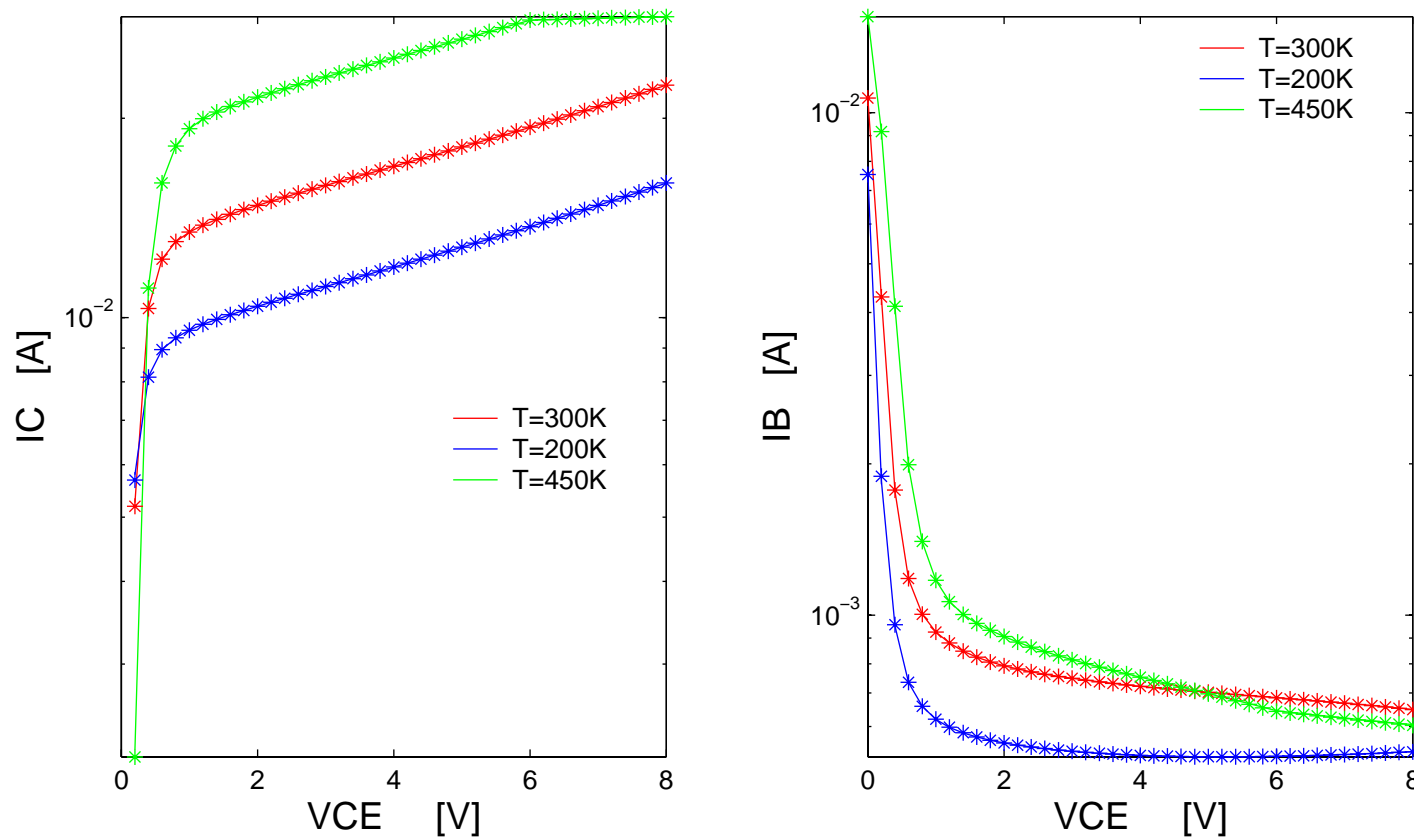
T=300K, FLSH=1, v2.22: continuous line, v2.11: symbols



Test results (contd.)

compatibility test with self-heating: output characteristics

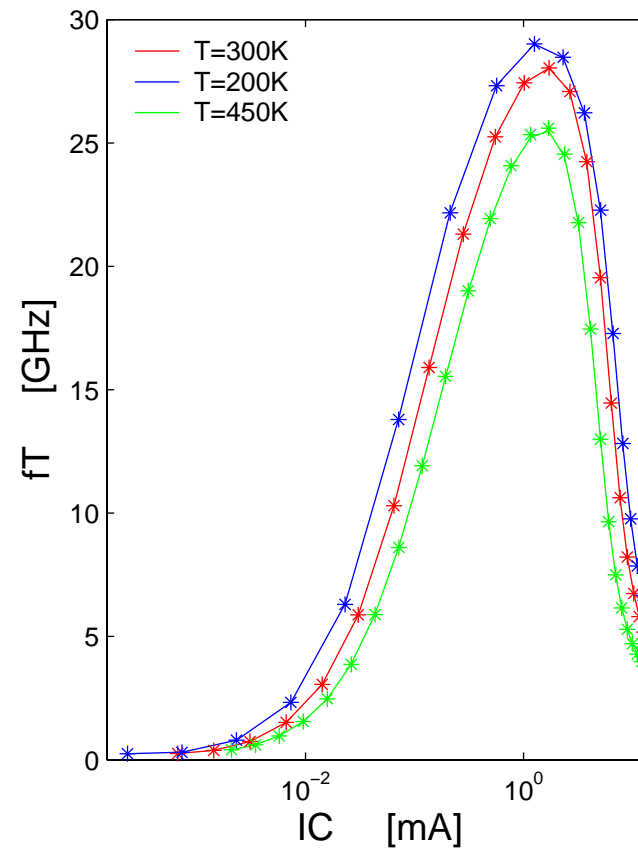
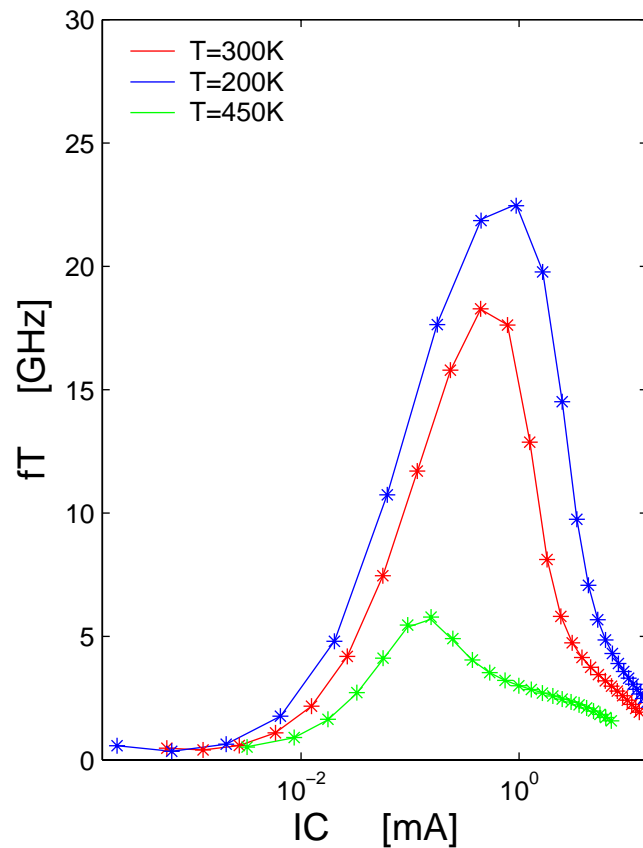
FLSH=1, $v_{be}=1.2V$, v2.22: continuous line, v2.11: symbols



Test results (contd.)

compatibility test with self-heating: transit frequency (@0.5GHz)

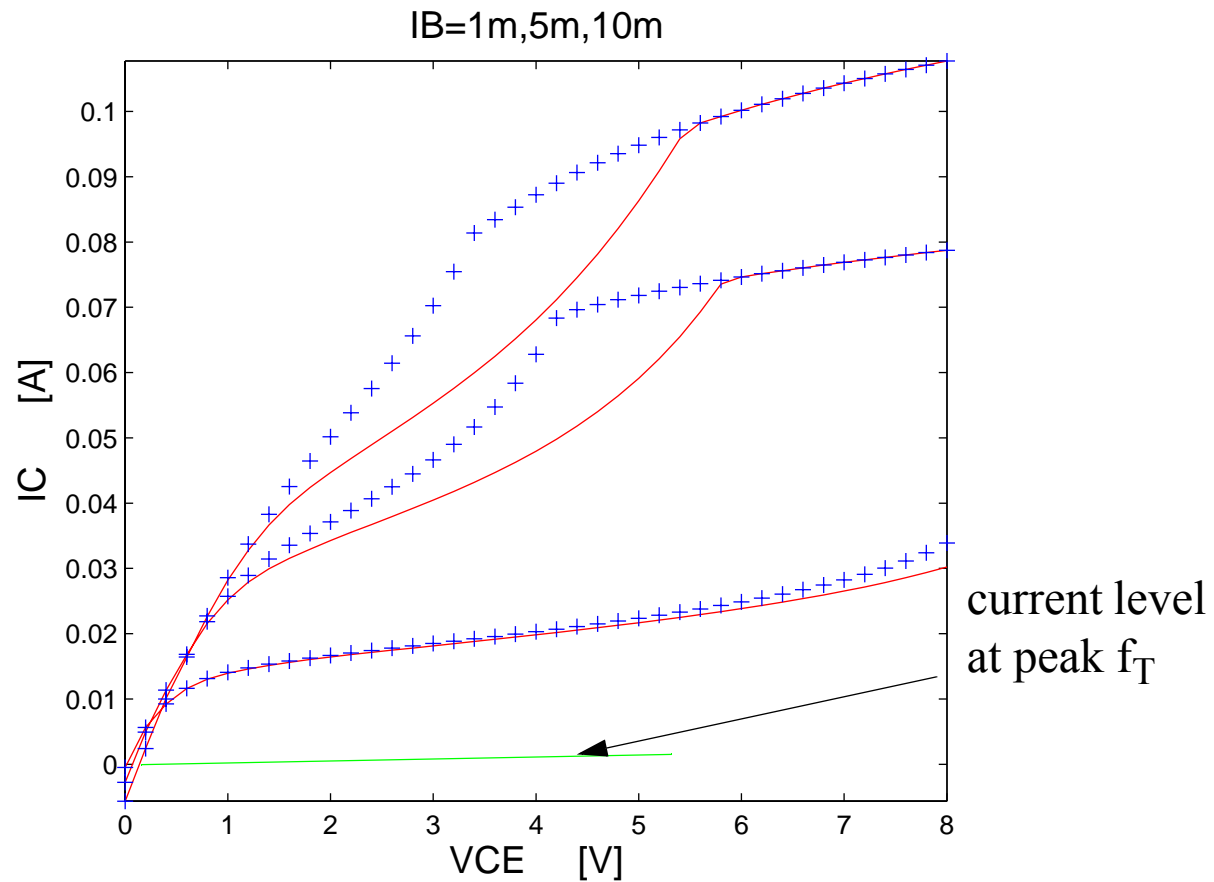
FLSH=1, vbc=0.5,-5.0V, v2.22: continuous line, v2.11: symbols



Test results (contd.)

comparison with self-heating: output characteristics

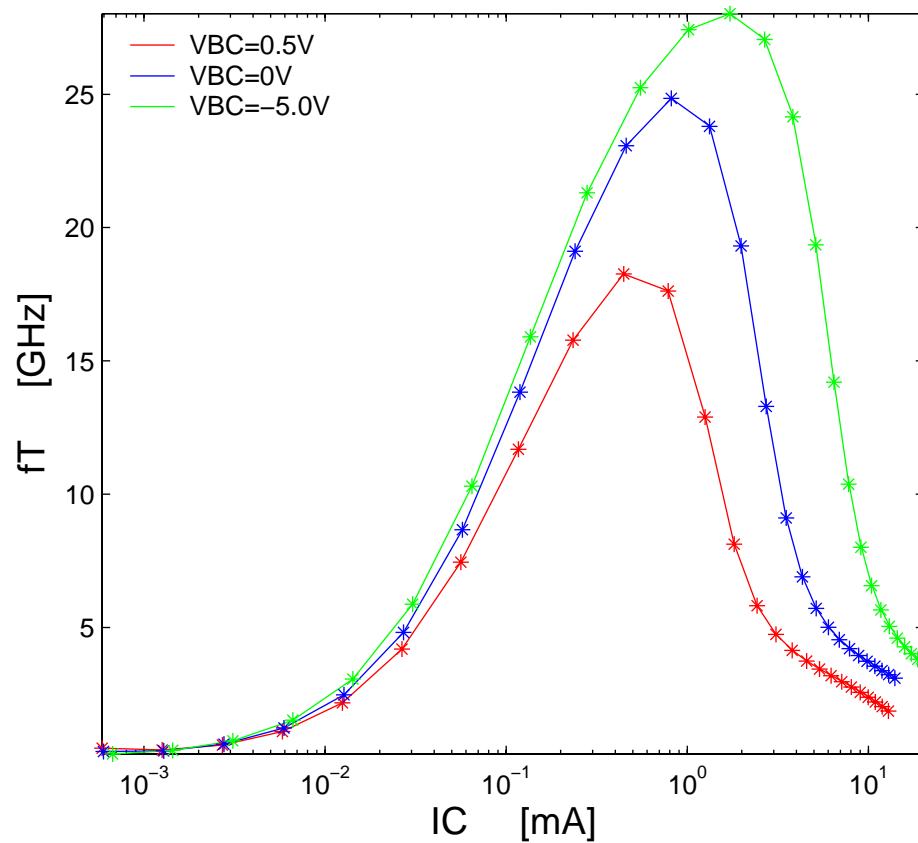
v2.22, T=300K, FLSH=1: continuous line, FLSH=2: symbols



Test results (contd.)

comparison with self-heating: transit frequency (@0.5GHz)

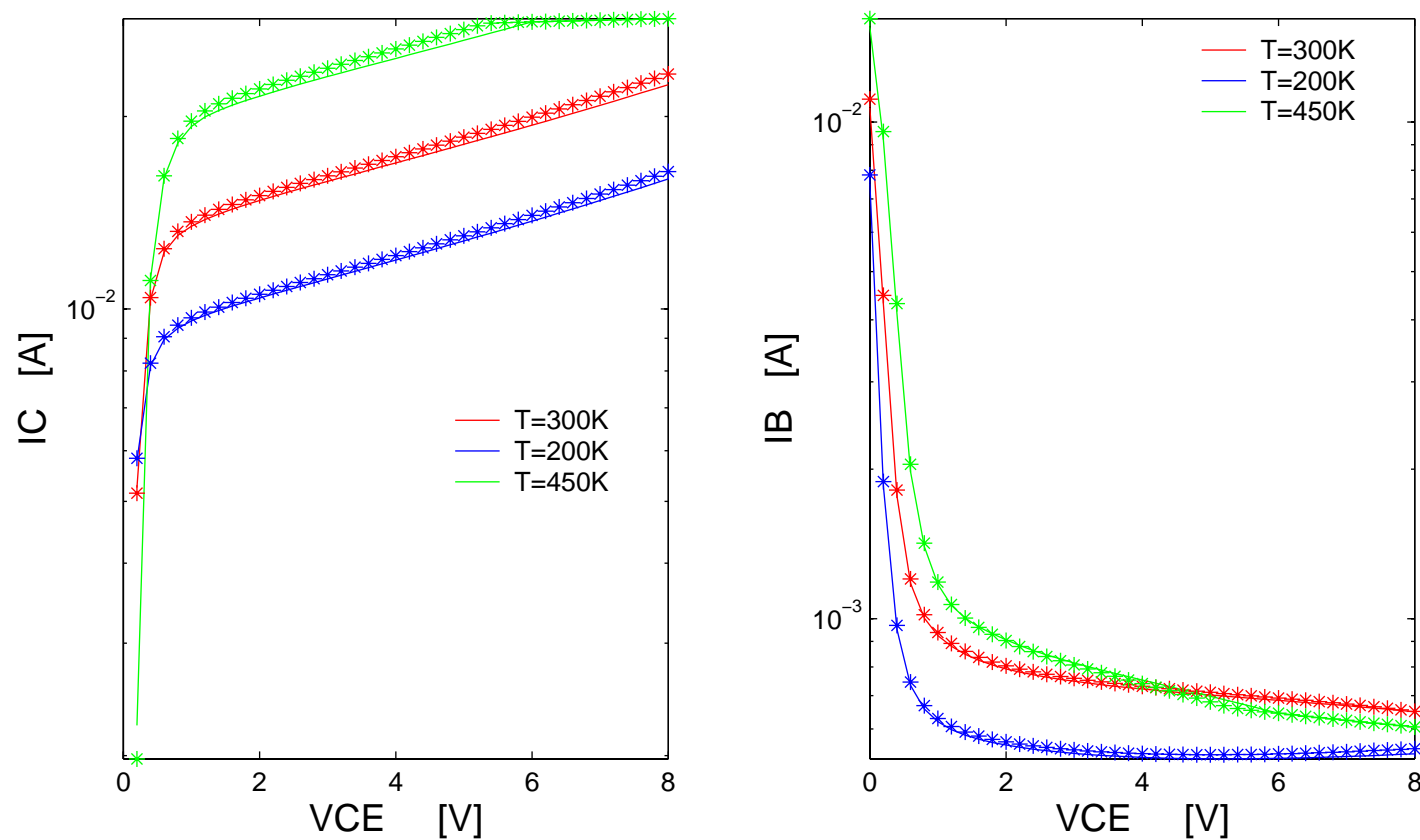
v2.22, T=300K, FLSH=1: continuous line, FLSH=2: symbols



Test results (contd.)

comparison with self-heating: output characteristics

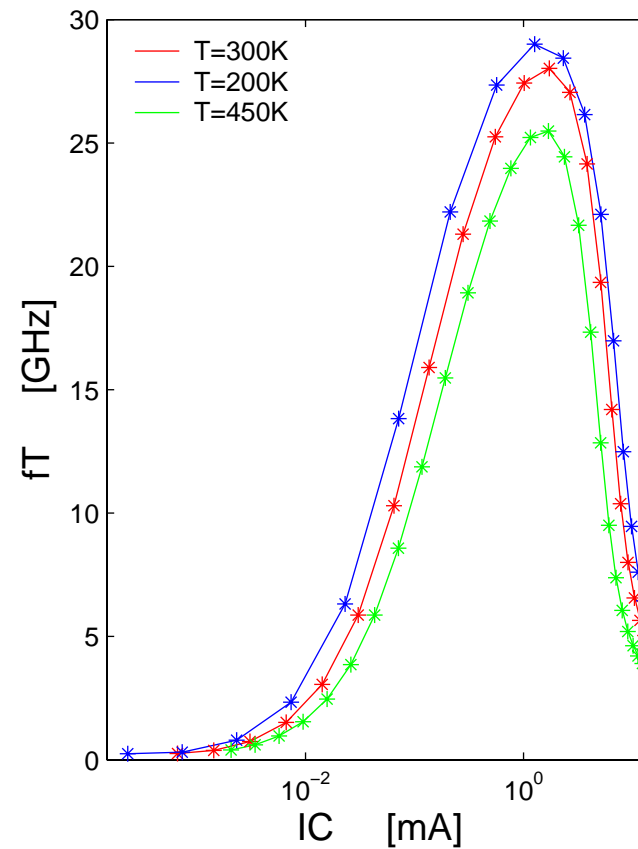
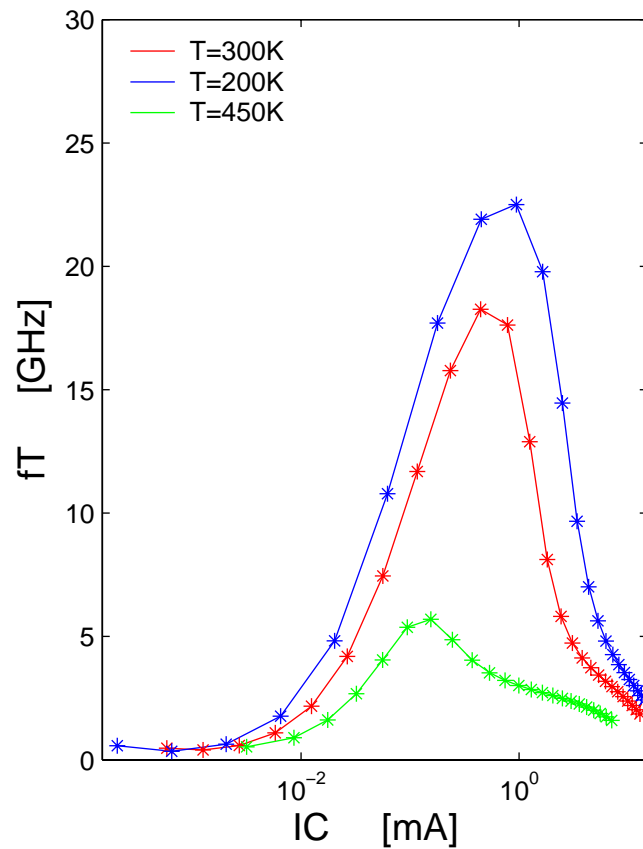
v2.22, vbe=1.2V, FLSH=1: continuous line, FLSH=2: symbols



Test results (contd.)

comparison with self-heating: transit frequency (@0.5GHz)

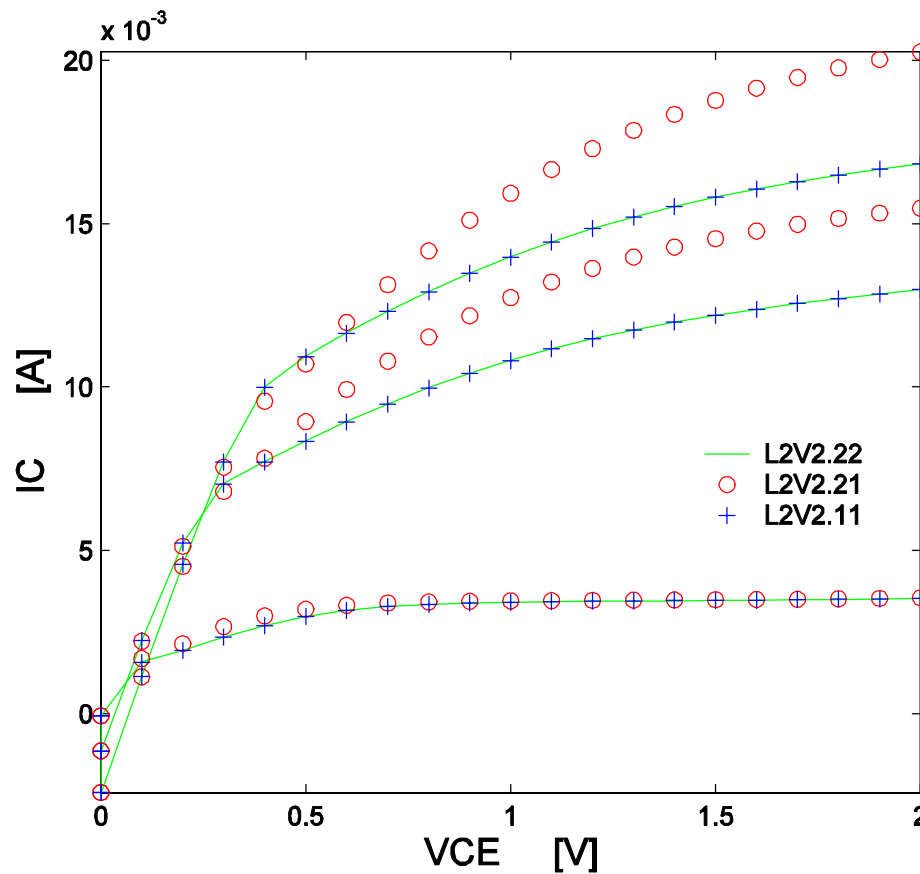
v2.22, vbc=0.5,-5V, FLSH=1: continuous line, FLSH=2: symbols



Test results (contd.)

compatibility with current spreading: output characteristics

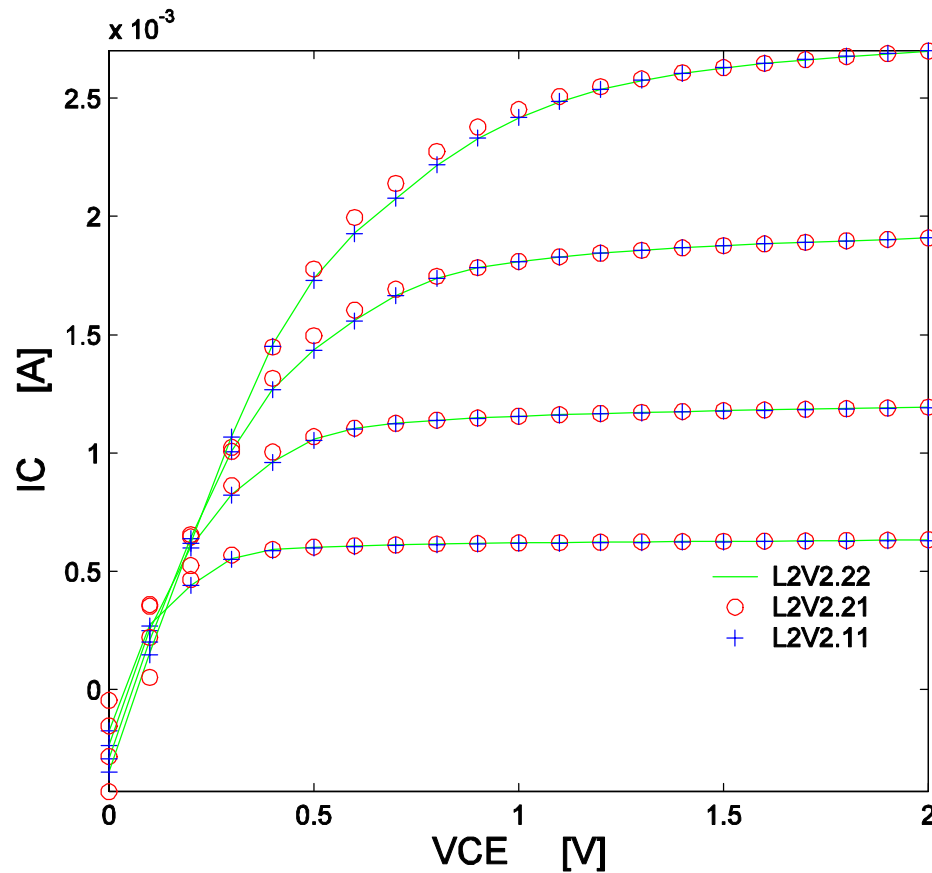
$v_{be}=1, 1.5, 2V$, $T=27^{\circ}C$



Test results (contd.)

compatibility with current spreading: output characteristics

$T = -75, -25, 25, 75 \text{ } ^\circ\text{C}$, $v_{be} = 1\text{V}$



Other activities

- Documentation
 - version 2.22 release notes available on web-site
 - latest documentation update: August '06
 - most recent results/development/information:
see website under "Events" => HICUM Workshop
- Code/implementation related investigations
 - correlated noise between base and collector current reported at BCTM06
 - Verilog-AMS specific coding: use of ddx()
 - compiler related information exchange (Freescale, Tiburon)

Version 2.3 in progress

funded by research grants

- NQS effect
 - investigating efficient way for implementing NQS effects
- Correlated Noise
 - investigating efficient option for implementation of proposed solution
- Field based model investigation
 - B-C depletion charge and capacitance as function of current *and* voltage
 - non-local B-C breakdown
 - improved physics-based model for base and collector related minority charge and transit time

HICUM/Level0

funded by research grants

- version 1.11 released in November'05
 - parameters given proper ranges
 - temperature related equations like in L2v2.22: including non-ideal base currents
 - diode currents limited to avoid convergence problem
 - thermal, shot and flicker noise included
 - implemented for NPN and PNP

v1.11:

$$I_{RES}(T) = I_{RES}(T_0) \left(\frac{T}{T_0} \right)^{m_g/2} \exp \left[\frac{V_{gBE}(0)}{2V_T} \left(\frac{T}{T_0} - 1 \right) \right]$$

- version 1.12 to be released
 - five-terminal model : thermal node set as external
 - introduction of flag FLSH (0,1,2): control of SH calculations
 - all series resistors and RTH will be limited to a minimum value : convergence
 - increase of code clarity
 - substrate transistor current added
 - hyperbolic smoothing in base resistance formulation to avoid divide-by-zero error (s. L2)
 - under test

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